UYEMURA Global Leader in Final Finish Technologies

- TWX-42 RAIG (Reduction-Assisted Immersion Gold) deposits 6-8 µm gold with zero nickel corrosion.
- Talon 3 electroless palladium: the foundation for ENEPIG, EPIG and EPAG final finish layer deposits
- TPD-23 electroless pure palladium for ENEPIG and wire bond applications
- **Direct Immersion Gold** for dense, non-porous deposits up to 0.3 μm; meets highest standards for HF and fine pattern compatibility

MEC from **Uyemura** Provides Industry's Roadmap for High Density and Ultra High Density Circuits

Etchbond optimizes copper bonding to resin, dry film or solder mask.



V-BOND 7710 is an H_2SO_4 - H_2O_2 - type microetchant with substantial cost and maintenance advantages compared with conventional oxide alternatives. It provides exceptional inner layer adhesion to all resins, including high Tg, HF (halogen-free), and PTFE.

Anisotropic Etching Enhancers including EXE-6722, improve sidewall profiles and enable finer lines and higher yields.

Flash and Differential Etchants for SAP/mSAP provide precise controlled etching and optimize sidewall geometries.



MEC from Uyemura IC Substrate Process Chart



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UYEMURA PRODUCTS

- **1** APPDES
- 2 ALCUP™
- 3 PEA
- 4 THRU-CUP™
- 5 MPC/MFD5/TALON/NPR/TWX

MEC PRODUCTS

- A STZ-3100 or STL
- B QE-7330, CI-7200
- C PJ-9720
- D HE-7002A
- CB-5002
- EXE SERIES
- G V-BOND B0-7710V
- CZ-2030, CZ-2050, or CZ-8201 (with CL-8300 or CL-2301)
- SF-5420
- CA-91Y, CB-801Y, CB-5620AY, or CA-5342
- **CA-5372** or **CA-5342**
- L CA-5342
- CA-5330K or CA-5344
- N CZ-5480

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